A TECHNIQUE FOR HIGH-FREQUENCY SCANNING OF HIGH POWER LASER LIGHT FOR LASER-WIRE SCANNERS AT ELECTRON ACCELERATORS*

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Abstract

Electro-optic techniques might allow implementing a laserwire scanner for intra-train scanning at the ILC with scanning speed in excess of 100 kHz. A scanner capable of running at such a rate would in fact provide information about the particle beam size in about one hundred different positions along the bunch train (approximately 1ms long for the ILC). The design of an electro-optic deflector capable to scan within 10-100 microseconds is presented, discussed and analytically treated.

INTRODUCTION

Laser-wires have been proposed in order to measure the properties of high energy electron beams, in particular the ILC [1], where electron and positron beams with energy up to 500 GeV will be collided and where the final focus spot-size will require demagnification of the vertical dimension to approximately 5nm. Some of the challenges posed by the ILC on the upstream laser-wire systems have been discussed [2]. In particular, it will be necessary to focus intense beams of laser-light down to micron scales and, in order to scan the electron beams within a single pulse (or train) of bunches, it will be necessary to scan at very high frequencies, in excess of 10-100 kHz. It has been proposed [3] to use electro-optic (EO) techniques for this purpose, exploiting the refraction at the output face of a prism made of EO materials; in this paper a different configuration of EO high-frequency driver is explored in order to obtain more efficient deflection strength.

PRINCIPLE OF OPERATION

The principle of operation of the presented device is based upon the generation of a linear gradient of electrostatic field across the transversal laser beam cross-section.

In fact, through the EO effect, an EO material experiences a change $\Delta n$ in the refractive index $n_0$ given by [4]:

$$\Delta n = \frac{1}{2} n_0^3 r_{33} E_z$$

(1)

where $r_{33}$ is the EO coefficient which couples the electrostatic field along the crystallographic c-axis and a parallel polarized light [note that the more general coupling formula is tensorial and eq. (1) is valid only for a particular class of materials such as the one treated in the text]. Now, if all along the EO crystal length an electrostatic field with linear transversal gradient is applied, the right side of the laser beam will travel at a different speed than the left one (the refractive index being different). This will result in a deflection of the wave-front directly proportional to the refractive index difference and the propagation length. The advantage of this configuration is obvious: the deflection obtainable increases by increasing the crystal length.

In order to obtain a linear gradient of the electro-static field, we propose to use EO crystals within an electro-static quadrupole configuration as shown in fig.1 While such devices are commercially available for low power applications, there are many challenges to obtain a large aperture device which would allow high-power laser use and optical quality sufficient for use within a laser-wire system (the largest clear aperture available in the market is around 3mm diameter).

DESIGN DETAILS

The problem of obtaining a large aperture EO scanner is fundamental. In fact, if an EO device with large clear aperture obtained with an EO crystal shaped as in fig. 1...
would require growing it with extremely large dimensions (16x16 mm² for a clear aperture of 6 mm) with obvious technical growth problems.

We propose a hybrid solution in order to overcome this problem. In fig. 2a is depicted a detailed drawing of a scanner with a clear aperture of 8.5 mm, capable to accept a beam diameter up to 7 mm (within the diffraction limit 8.5 mm/1.22 [4]).

Using the dimensions as in fig 2a, we realized a prototype with hyperbolic electrodes and a 50 mm long crystal of LNB (being grown at the time of writing). In fig. 2b is reported a picture of the realized crystal holder with hyperbolic electrodes.

Furthermore, the hybrid solution we present is extremely flexible, it indeed allows us to change the electrode shape just by producing a differently shaped holder (made in our facilities using inexpensive materials), in order to optimize the distribution of the electro-static field within the EO material. In fact, in the following an analytical treatment of the problem is presented and a numerical optimization of the electrodes’ shape and relevant dimensions obtained.

**ANALYTICAL TREATMENT**

If the electric field is made up of a dominant linearly dependent (quadrupole) component \( x dE_z / dx \) plus an additional component \( \delta E_z \) due to the presence of higher-order multipoles, so that \( E_z = x dE_z / dx + \delta E_z \). The effect will be a rotation \( \Delta \theta \) of the wavefront after transmission through a length \( L \) of crystal is given by:

\[
\Delta \theta = \frac{dn}{dx} L = \frac{1}{2} r_{33} L \frac{dE_z}{dx}
\]

plus a residual distortion proportional to the term \( \delta E_z \) which is currently being calculated and minimized.

The EO crystal we consider (LNB) has a non-isotropic permittivity, characterized here by two values \( \varepsilon_{33} \) along the electro-optic axis (the vertical axis in Fig 1) and \( \varepsilon_{11} \) along the perpendicular axis.

In the following we define \( \varepsilon_{ij} = (\varepsilon_{ij} + \varepsilon_{33})/2 \) and \( \Delta \varepsilon_i = (\varepsilon_{ij} - \varepsilon_{33})/2 \). We also introduce dimensionless variables \( \rho = r/D \), \( \eta = R/D \), where \( r \) is the radial variable, \( D \) the inner (minimum) distance between the centre of the device and the high-voltage electrode with applied electric potential \( V_0 \), and \( R \) is the radius of the crystal as illustrated in Fig. 2a.

The outer material has relative permittivity \( \varepsilon_0 \). In general, when \( \rho \leq \eta \) for a perfect quadrupole field \( V = V_0 \rho^2 \sin 2\theta \) and for \( \rho > \eta \):

\[
\frac{V}{V_2} = \frac{1}{2} \left[ \left( 1 + \frac{\varepsilon_1}{\varepsilon_2} \right) \rho^2 + \left( 1 - \frac{\varepsilon_1}{\varepsilon_2} \right) \eta^4 \right] \sin 2\theta + \frac{1}{8} \frac{\Delta \varepsilon_1}{\varepsilon_2} \left[ \frac{\rho^4}{\eta^2} - \frac{\eta^8}{\rho^4} \right] \sin 4\theta.
\]

The gradient of the \( y \)-component of the electric field \( E_z \) within the crystal is then:

\[
\frac{dE_z}{dx} = \frac{2V_2}{D_i^2}
\]

The relationship between applied voltage \( V_0 \) and the parameter \( V_2 \) is given by:

\[
\frac{V_0}{V_2} = \frac{1}{2} \left[ \left( 1 + \frac{\varepsilon_1}{\varepsilon_2} \right) \rho^2 + \left( 1 - \frac{\varepsilon_1}{\varepsilon_2} \right) \eta^4 \right].
\]
Ideally $\eta$ should be as close to 1 as possible in order to maximize the electric field within the crystal; for the parameters listed in Tab.1, $V_0/V_z = 4.8$.

The shape of the electrode that is needed to obtain a quadrupole field within the crystal can be obtained by imposing $V(\rho\theta) = V_0$ in Eq.3; the resulting electric equipotential lines and electrode optimized shape are shown in fig.3. The exact shape and dimensions of the system needs to be optimized in order to improve the linearity of the fields within the crystal; alternative configurations of electrodes are currently under study.

The scanner has the dimensions as in Tab.1. By applying a ramp from 0 to 5kV we expect a deflection of 0.75 mrad ($2.9\mu rad \cdot V^{-1} \cdot mm^{-1} \times 5kV \times 50mm$). Focusing this beam with a 100 mm lens we can obtain a beam waist of 5μm ($\sigma=2.5\mu m$) and a scan range of 75μm.

For measuring the profile and the position of every second pulse of the scanned laser beam, we will use a CCD line camera, consisting of a single row of 1024 pixels, can be read out via Ethernet at a rate in excess of 68kHz.

The large bandwidth of the HV amplifier will allow amplifying a step function of 10 steps around 8μs each, in a way to scan ten laser pulses in ten different positions within 80μs. In case an average over multiple interaction has to be done, each step will be as long as a multiple of the laser pulse spacing (7.7 μs).

**CONCLUSION**

In conclusion, we proposed a hybrid solution for an EO scanner with large aperture capable of operating with high laser power. The calculated deflection is expected to be 0.75 mrad for a laser beam diameter of 7mm. The expected $\sigma$ of 2.5μm and scan range of 75 μm makes it suitable for a fast laserwire scanner.

Experimental test on the realized prototype are being performed using a laser at 130 kHz and a HV ramp as short as 80μs.

Furthermore, the presented analytical model will enable us to optimize the electrode shape for more efficient performances.

**REFERENCES**